

IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

Applicant: **Leonard J. Olmer, et al**



Art Unit: **1746**

Serial No.: **10/675,575**

Examiner: **El Arini, Zeinab**

Filed: **09/30/2003**

Confirmation No.: **9967**

Attorney Docket No.: **Bervers 2-3-16-20/075903-81**

For: **In-Situ Removal of Surface Impurities Prior to Arsenic-Doped Polysilicon
Deposition in the Fabrication of a Heterojunction Bipolar Transistor**

AMENDMENT

January 20, 2006

Mail Stop Amendment
Commissioner for Patents
P.O. Box 1450
Alexandria, VA 22313-1450

Dear Sir or Madam:

In response to the Office Action mailed on September 20, 2005, please amend the subject application as follows.